

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Title: HIGH INDEX AND HIGH IMPACT RESISTANT POLYTHIOURETHANE/UREA  
MATERIAL, METHOD OF MANUFACTURING SAME AND ITS USE IN THE  
OPTICAL FIELD

Appl. No.: 09/992,054

Applicants: Jallouli *et al.*

Filed: November 14, 2001

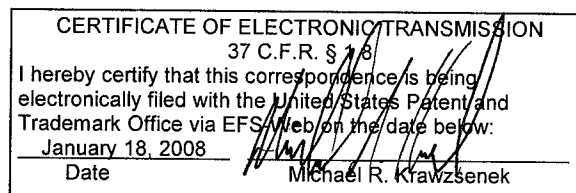
TC/A.U.: 1796

Examiner: Sergeant, Rabon A

Docket No.: ESSR:058US

Customer No.: 32425

Confirmation No. 4850



**SUBMISSION UNDER 37 C.F.R. § 1.114**

**MAIL STOP RCE**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Applicants submit this Submission under 37 C.F.R. § 1.114 in response to the Office Action mailed October 18, 2007. Applicants are concurrently filing a Request for Continued Examination ("RCE") with this Submission where the required fee of \$790.00 (large entity) is being charged to a credit card through EFS-Web. The Commissioner is authorized to deduct any underpayment of fees or any additional fees required under 37 C.F.R. §§ 1.16 to 1.21 with the filing of this paper from Fulbright & Jaworski Deposit Account No. 50-1212/ESSR:058US.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2.

**Remarks/Arguments** begin on page 10.